P. N1



Patent

Customer No.: 31561 Docket No. 12474-US-PA Application No.: 10/711,379

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Applicant

: Lu et al.

Application No.

: 10/711,379

Filed

: September 15, 2004

For

: METHOD OF PLANARIZING SPIN-ON MATERIAL

LAYER AND MANUFACTURING PHOTORESIST LAYER

Art Unit

: 2818

Examiner

: NHU, DAVID

RESPONSE TO NOTICE REGARDING DRAWINGS

+1-703-746-4000 (Via fax: 1+9 pages)

U.S. Patent and Trademark Office Customer Service Window, Mail Stop <u>Issue Fees</u> Randolph Building 401 Dulany Street Alexandria, VA 22314

Dear Sir,

In reply to the Notice Regarding Drawings mailed on August 26, 2005, transmitted herewith please find Replacement Sheets for corrected drawings in 9 pages.

Thank you for your assistance in the subject matter. If you have any questions, please feel free to contact me.

Respectfully Submitted,
JIANQ CHYUN Intellectual Property Office

Date: 13,2005

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